## Bendable crystals in Bragg geometry

Thierry Moreno, François Baudelet, Sylvain Brochet, Sébastien Chagnot, Alberta Congeduti, Mourad Idir, Quingyu Kong, Muriel Thomasset SOLEIL SYNCHROTRON

- Overview of focusing
- Hooke's law + parameters
- ODE beamline description
- Data analysis
- Conclusion

O Image size $\rightarrow$ two factors : source size and mirror defects

$$
\sigma_{\text {IMAGE }}=\left(\sigma_{\text {SOURCE }} \frac{\mathrm{q}}{\mathrm{p}}\right) \otimes(2 \mathrm{q} \varepsilon)
$$



- Radius of curvature

$$
\mathrm{R} \approx \frac{2 \times \mathrm{q}}{\sin (\theta)} \quad\left\{\begin{array}{l}
\text { Long mirrors : } 50 \mu \mathrm{~m}, 5000-1000 \mathrm{~m}, 60 \mathrm{~mm} \\
\text { KB mirrors : } 2 \mu \mathrm{~m}, 150-50 \mathrm{~m}, 8 \mathrm{~mm} \\
\underline{\text { Sil11 crystal at } 7 \mathrm{keV}: 10-8 \mathrm{~m}, 1.5 \mathrm{~mm}}
\end{array}\right.
$$

## Overview of focusing

- slope error effect on the focus



## Overview of focusing

- slope error effect on focus



## Overview of focusing

- slope error shape out of focus


$\Rightarrow$ sinusoidale defects resulting of - polishing defects (mirrors) - thickness and width defects (crystals)


## Overview of focusing

- Sinusoidale defects in crystals

Sil11 crystal at $7 \mathrm{keV}\left(\theta=16.41^{\circ}\right)$
Sine defect : $A=1.8 \boldsymbol{\mu m}, \mathrm{D}=\mathbf{8 0} \mathrm{mm}, \mathrm{L}=\mathbf{2 0 0} \mathrm{mm}$

DUMOND Diagrams


The DUMOND Diagram changes according to the position of the detector

O Local crystal curvature effect (Using Takagi-Taupin crystal theory)


## Overview of focusing

- Depth penetration length effect


If only absorption

$\Rightarrow$ Focal size limitation for crystals

## Hooke's law

- Hooke's law definition

$$
\frac{1}{R(x)}=\frac{12}{\mathrm{Eh}^{3}} \frac{\frac{\left(\mathrm{C}_{1}+\mathrm{C}_{2}\right)}{2}-\frac{\left(\mathrm{C}_{1}-C_{2}\right)}{\mathrm{L}} \mathrm{x}}{\mathrm{~b}(\mathrm{x})}
$$


$\Rightarrow$ elastic deformations
$\Rightarrow$ mechanical beam theory

$$
\frac{1}{100}<\frac{h}{L}<\frac{1}{5}
$$



$$
\begin{aligned}
& \text { Long mirrors, KB : } \frac{1}{20} \\
& \text { Bent crystals : } \frac{1}{100} \approx \text { Plate theory } \rightarrow \text { (FEA verification) }
\end{aligned}
$$

- Curvature
$\frac{1}{R(x)}=\frac{12}{E h^{3}} \frac{\frac{\left(C_{1}+C_{2}\right)}{2}-\frac{\left(C_{1}-C_{2}\right)}{L} x}{b(x)}$


$$
\frac{1}{R(x)}=\frac{y^{\prime \prime}(x)}{\sqrt[3]{1+y^{\prime}(x)^{2}}} \approx y^{\prime \prime}(x)
$$


$\Rightarrow$ evaluation

$$
\begin{aligned}
& \varepsilon=\text { у' }_{\text {нооке }}-\text { у' }_{\text {ELL }} \\
& \rightarrow \sigma=2 \times \varepsilon \times \mathrm{q}
\end{aligned}
$$

- Ellipse representation

$$
\begin{aligned}
& \Rightarrow \text { Polynomial } y_{E L L}=\sum a_{n} x^{n} \\
& \text { with } a_{n}=f(p, q, \theta) \\
& \Rightarrow \text { Numerical }\left(x_{1}, y_{1}\right) \ldots\left(x_{N}, y_{N}\right)
\end{aligned}
$$

Polynomial representation :
Sil11 ODE crystal
$\mathrm{p}=17.2 \mathrm{~m}, \mathrm{q}=1.2 \mathrm{~m}, \theta=16.41^{\circ}(7 \mathrm{keV})$
LUCIA HFM
spot of $\mathbf{1 0} \mu \mathrm{m}$ FWHM



## Hooke's law

- Width side

$$
\frac{1}{R(x)}=\frac{12}{E h^{3}} \frac{\frac{\left(C_{1}+C_{2}\right)}{2}-\frac{\left(C_{1}-C_{2}\right)}{L} x}{b(x)} \quad \begin{aligned}
& \text { shapes } \\
& \text { free : numerical }
\end{aligned} \begin{aligned}
& \left(x_{1}, b_{1}\right) \ldots\left(x_{N}, b_{N}\right) \\
& \text { trapezoidal } \\
& \begin{array}{l}
\text { torpedo }
\end{array} \\
& b(x)=A(1-B x) \rightarrow A \\
& b(x)=A\left(1-B x^{2}\right)
\end{aligned} \rightarrow B
$$

Si111 ODE crystal, $\mathrm{L}=300 \mathrm{~mm}, \mathrm{~h}=1.6 \mathrm{~mm}$ $p=17.2 \mathrm{~m}, \mathrm{q}=1.2 \mathrm{~m}, \theta=16.41^{\circ}(7 \mathrm{keV})$


$\Rightarrow$ Trapezoidal easier to make and to correct
$\Rightarrow$ Torpedo well adapted for bending and thermal cooling because symmetric

## Hooke's law

- Change of energy

Si111 ODE crystal, $\mathrm{L}=300 \mathrm{~mm}, \mathrm{~h}=1.6 \mathrm{~mm}$ $\mathrm{p}=17.2 \mathrm{~m}, \mathrm{q}=1.2 \mathrm{~m}$
Triangular width optimized at $7 \mathrm{keV}\left(\theta=16.41^{\circ}\right)$


| $E(\mathrm{keV})$ | $\theta\left({ }^{\circ}\right)$ | $\mathrm{C}_{1}$ (N.m) | $\mathrm{C}_{2}$ (N.m) |
| :--- | :--- | :--- | :--- |
| 5 | 23.30 | 0.2018 | 0.2077 |
| 6 | 19.24 | 0.1675 | 0.1739 |
| 7 (opt) | 16.41 | 0.1432 | 0.1495 |
| 10 | 11.41 | 0.1000 | 0.1050 |

$\Rightarrow$ The RMS slope error is acceptable for a large spectral domain
$\Rightarrow$ The residual slope error shape may structured the Dumond diagram

## Hooke's law

O thickness

$$
\frac{1}{R(x)}=\frac{12}{E h^{3}} \frac{2}{b(x)}
$$

$\Rightarrow$ Thickness defects can be corrected with the lateral width

$$
\begin{aligned}
& (h+\Delta h)^{3}(b+\Delta b)=c t e \rightarrow \Delta b=\frac{3 b}{h} \Delta h \quad(h=1.6 \mathrm{~mm}, \mathrm{~b}=30 \mathrm{~mm} \rightarrow \approx 60 \mu \mathrm{~m} / \mu \mathrm{m}) \\
& \text { ss variation }( \pm 2 \mu \mathrm{~m})
\end{aligned}
$$

Thickness variation ( $\pm 2 \mu \mathrm{~m}$ )


Width variation



## ODE EDXAS beamline

- ODE beamline : EDXAS
$\Rightarrow$ X-ray magnetic Circular Dichroism
$\Rightarrow$ Materials under extreme conditions
$\Rightarrow$ Chemistry and time resolved measurements

- Bent crystal

$\Rightarrow$ Adapted to the bending and cooling Difficult to make

$\Rightarrow$ Adapted to the bending
No adapted to the cooling Easy to make


Adapted to the bending ?
Adapted to the cooling Easy to make

$\square$
Have to be checked by FEA

## X-ray measurements

- Zn edge measurement
$\Rightarrow E=9659 \mathrm{eV}, \theta_{0}=11.81^{\circ}, \Delta E=600 \mathrm{eV}$



CCD : 110×72 pix (7 $\mu \mathrm{m} / \mathrm{pix}$ )

Equivalent sine defect
$q_{\text {striation }}=1200 \pm 8 \mathrm{~mm}$ $\delta=114 \mu \mathrm{~m}$

$\rightarrow A=100 \mathrm{~nm}, \mathrm{D}=80 \mathrm{~mm}, \varepsilon=5.3 \mu \mathrm{rad}$ RMS
$\Delta \mathrm{x}_{\text {the }}=30 \mu \mathrm{~m}$ FWHM
$\Delta x_{\text {mes }}=45 \mu \mathrm{~m}$ FWHM (factor 1.5)

## Data analysis

- Thickness crystal measurement
$\Rightarrow$ Use of a profilometer : the support of the crystal is critical



Thickness reconstruction


Next step : to use a fixed crystal curvature for the profilometer measurement

## Data analysis

- Shape of the surface

$\Rightarrow$ The optical shape varies with the Bragg angle
$\Rightarrow$ The optical shape is very sensitive with $\mathrm{C}_{1}$ and $\mathrm{C}_{2}$
$\Rightarrow$ Period $=80 \mathrm{~mm}$


## Data analysis

- $\mathbf{Z n}$ edge simulations
$\Rightarrow E=9659 \mathrm{eV}, \theta_{0}=11.81^{\circ}, \Delta E=600 \mathrm{eV}$
$\Delta q=-8 \mathrm{~mm}$

$$
\begin{gathered}
\Delta q=0 \mathrm{~mm} \\
\text { at focus }
\end{gathered}
$$



## Data analysis

- Comparison experience - theory
$\Rightarrow E=9659 \mathrm{eV}, \theta_{0}=11.81^{\circ}, \Delta E=600 \mathrm{eV}$


Structures out of focus correctly depict through thickness defects

Focal spot size strongly dependent of depth penetration (not yet implemented on the ray tracing)

- Intensity modulation scheme
$\Rightarrow$ Intensity modulation = f( source size, period defects, beam divergence)

$\diamond$ Olivier Mathon, ESRF
$\diamond$ François Polack, Gilles Cauchon and Rachid Belkhou, SOLEIL
$\diamond$ ODE beamline team and Metrology Laboratory team of SOLEIL


## Simulations tools

- Ray tracing software SPOTX
$\Rightarrow$ Based on the MonteCarlo method
$\Rightarrow$ Dynamical absorption calculation
$\Rightarrow$ Very fast and well suited for X-ray beamlines simulations
- Surfaces defects
$\Rightarrow$ Function (sinusoidal, ..)
$\Rightarrow$ Random
$\Rightarrow$ Data file : profilometer, interferometer

